

Light-Assisted Batch Injection Analysis of Glucose Exploiting a p-n-Homojunction Based on Cu₂O

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This work describes the development of a photoelectrochemical sensor for glucose quantification exploiting a light assisted-batch injection analysis (BIA) cell. A light-emitting diode (LED) lamp was employed to control the incidence of light on the p-Cu₂O/n-Cu₂O/fluorine-doped tin oxide (FTO) photoactive platform in BIA cell. The p-Cu₂O/n-Cu₂O/FTO platform was constructed by electrodepositing n-Cu₂O and p-Cu₂O and the characteristics of electrodeposited Cu₂O films were investigated by X-ray diffraction (XRD), Raman spectroscopy, and electrochemical impedance spectroscopy. The light assisted-batch injection analysis of glucose based on the illuminated p-Cu₂O/n-Cu₂O/FTO photoelectrode presented a linear response of 10 μmol L⁻¹-1 mmol L⁻¹, a limit of detection of 4.0 μmol L⁻¹, and sensitivity of 0.768 ± 0.011 μA L μmol⁻¹ cm⁻². The system presented an average recovery value of 96% when applied to the determination of glucose in an artificial saliva sample, which indicates that the incidence of light on photoelectroactive platforms is a promising approach for the determination and quantification of glucose.

Keywords: batch injection analysis, copper(II) oxide, glucose, LED light

Introduction

Glucose is an essential monosaccharide for the proper functioning of living organisms.¹ Nevertheless, high levels of glucose in the blood can result in the development of diabetes.^{2,3} Diabetes is one of the most expressive causes of mortality nowadays, and it is linked to the development of several pathologies.⁴ In this sense, the development of sensitive and reliable glucose detection devices is of high importance, and different approaches have been developed with this aim, including methods based on chromatography,⁵ colorimetry,⁶ spectroscopy⁷ and sensors.⁸⁻¹⁰

Nowadays the development of enzymatic and non-enzymatic sensors for glucose detection have received high attention due to its exquisite properties. On the one hand, enzymatic glucose sensors are mainly based on the immobilization of the enzyme glucose oxidase (GOx) on various substrates and currently they play an important role in the detection of blood glucose due to its high selectivity and sensitivity.^{11,12} On the other hand, non-enzymatic sensors for glucose are based on the direct electro-oxidation

of glucose on the surface of a catalyst. Therefore, non-enzymatic sensors for glucose do not require the use of enzymes which contribute to the stability, simplicity and reproducibility of the platforms developed for glucose detection.¹³ Among the several classes of sensors recently proposed for glucose determination, the electrochemical methods appear as an inexpensive, fast, accurate, sensitive, and portable, being a low-cost and straightforward alternative to measure glucose levels in different types of samples.¹⁴

In the last decade, the photoelectrochemical effect in semiconductor materials has been widely explored as a transduction process for detecting and quantifying several species,¹⁵ presenting one of the highest sensitivity among the methods based on electrochemical detection. The photoelectrochemical systems have opened new perspectives in sensor area since they can operate with low noise and background current due to the separation between the excitation light source and the photocurrent detector.¹⁶

Pioneering works in the development of photoelectrochemical platforms have opened new perspectives in determination of glucose, including photoelectrochemical enzymatic systems,¹⁷ photoelectrochemical non-enzymatic systems,¹⁸ photoelectrochemical systems based on flow

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Editor handled this article: Rodrigo A. A. Muñoz (Associate)

injection analysis,¹⁹ and recently photoelectrochemical systems based on batch injection analysis.²⁰

In addition, several photoelectroactive materials, such as semiconducting-metal-oxide-based materials, because of their interesting electrical and optical properties, have been exploited, being suitable candidates for the construction of photoelectrochemical sensors.²⁰ Among these materials, copper(I) oxide (Cu₂O) has shown an impressive electrochemical catalytic activity for glucose oxidation.²¹⁻²⁵

Cuprous(I) oxide (Cu₂O) is commonly a p-type semiconductor, and it presents a direct bandgap of around 2 eV. In addition, Cu₂O shows a high absorption coefficient, abundance on Earth, non-toxic behavior and low-cost manufacturing.²⁶ Although Cu₂O is naturally a p-type semiconductor, due to copper vacancies in its structure, it is possible to obtain Cu₂O as an n-type semiconductor, which occurs due to oxygen deficiency in its crystalline network.²⁷

The properties of cuprous oxide-based materials can be intensified by exploiting the homojunction based on p-type (p-Cu₂O) and n-type (n-Cu₂O) films. Considering that the electronic affinity of the cuprous oxides p-Cu₂O and n-Cu₂O are approximately equal, junctions based on these materials can decrease the discontinuity of the conduction band along the interface. Therefore, it is possible to form a high-quality interface through a homojunction p-n or n-p, considering that the position of the conduction and valence bands of p-Cu₂O and n-Cu₂O are close.²⁸

The search for fast, sensitive, simple, reproductive, versatile analytical methods motivated research groups to develop methods based on self-sampling,²⁰ such as batch injection analysis, for example, which shows attractive features, including high throughput analysis,²⁹ easy handling system,³⁰ precision,³¹ accuracy,³² use of small sample volumes, high sensitivity, low cost, simplicity and portability.³³

Therefore, the combined use of batch injection analysis to Cu₂O based photoelectrochemical platforms can provide improvement of sensitivity, precision, detectability, and improve the throughput analysis. This work aims to develop, at first time, a photoelectrochemical assisted batch-injection analysis system based on a p-Cu₂O/n-Cu₂O/fluorine-doped tin oxide (FTO) photoelectrode for glucose determination.

Experimental

Reagents and materials

All chemicals used in this study were analytical grade, and they were used without further purification steps.

Copper sulfate (CuSO₄), tartaric acid (C₄H₆O₆), copper acetate monohydrate (Cu(CH₃COO)₂·H₂O), acetic acid (CH₃COOH), glucose (C₁₂H₂₂O₁₁), sodium chloride (NaCl), potassium chloride (KCl), calcium chloride dihydrate (CaCl₂·2H₂O), sodium bicarbonate (NaHCO₃), sodium hydroxide (NaOH), sodium sulfate (Na₂SO₄) and ethyl alcohol (C₂H₆O) were purchased from ISOFAR (Duque de Caxias, Rio de Janeiro, Brazil). Glass plates with a surface covered with a transparent layer of fluorine-doped tin oxide (FTO), and potassium ferricyanide (K₃[Fe(CN)₆]) were purchased from Sigma-Aldrich (St. Louis, USA). The working solutions were prepared daily with water purified in an OS100LXE system from GEHAKA Company (São Paulo, Brazil).

Construction of the p-Cu₂O/n-Cu₂O/FTO photoelectrochemical sensor

Initially, the glass slides coated with a layer of fluorine-doped tin oxide (FTO) were extensively rinsed with water and ethanol to remove any previously adsorbed species from the FTO surface. After that, n-type and p-type Cu₂O films were deposited on the FTO surface. The electrodeposition of n-type Cu₂O film was performed from bath solutions containing 0.02 mol L⁻¹ Cu(CH₃COO)₂·H₂O and 0.08 mol L⁻¹ CH₃COOH. The pH of the medium was adjusted to 4.9 with NaOH solution, and the FTO working electrode was biased at +0.02 V vs. Ag/AgCl for 1200 s at a temperature of about 70 °C.³⁴ On the other hand, p-type Cu₂O films were electrodeposited from a plating solution containing 0.1 mol L⁻¹ CuSO₄ and 0.1 mol L⁻¹ tartaric acid. After adjusting the pH to 11 with NaOH solution, the temperature of the electrodeposition bath was maintained at about 60 °C with aid of a hotplate equipped with ceramic surface from Kasvi (São José dos Pinhais, Brazil) and monitored with a thermometer, and the electrochemical platform was biased at -0.4 V vs. Ag/AgCl during 300 s to produce the p-Cu₂O modified photoelectrodes.^{34,35}

Raman, X-ray diffraction and (photo)electrochemical measurements

Raman measurements were performed with a Horiba-Jobin-Yvon triple spectrometer, model T64000 (Kyoto, Japan), operating in the single-mode and equipped with a liquid-N₂-cooled charge-coupled device detector. A green 532 nm line from a solid-state laser (LAS-532-100 HREV) operating at 14 mW was employed for excitation, and the slit was adjusted to give a resolution of 2 cm⁻¹. An Olympus microscope with an MPLN 50× objective lens was employed to adjust the light beam on the

photoelectrochemical platforms. The intensity of the laser on the photoelectrochemical platform was adjusted with an ND 0.6 optical density filter (25% transmission). The spectra of the samples were obtained after 5 acquisitions of 30 s each at each range of the grade spectral dispersion.

The X-ray diffractograms (XRD) were performed with a Bruker D8 Advance diffractometer (Bruker AXS, Karlsruhe, Germany), equipped with the LynxEye linear detector, using Cu K α ($\lambda = 1.5406 \text{ \AA}$) operating at 40 kV and a current of 40 mA. The X-ray diffractograms were performed in a 2θ ranging from 25–75° with a counting time of 0.5 s, step size of 0.02° and Bragg-Brentano geometry.

The photocurrent measurements were performed with a potentiostat/galvanostat model PGSTAT 128N from Metrohm Autolab BV (Utrecht, Netherlands). A light assisted batch injection analysis cell with a photoelectrochemical platform as working electrode, a platinum wire as counter electrode and an Ag/AgCl_(sat) as reference electrode was employed for photoelectrochemical measurements. The batch injection analysis cell is composed of the glass cell and a cover with three orifices for the reference electrode, counter-electrode and micropipette, and a support for the positioning of the working electrode (Figure 1).

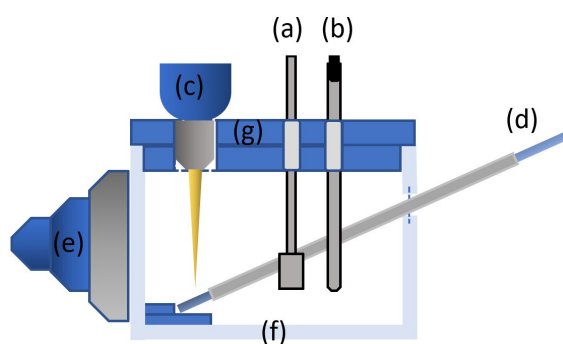


Figure 1. Photoelectrochemical batch injection analysis (PEC-BIA) cell for the electrochemical determination of glucose. (a) Auxiliary-electrode; (b) reference electrode; (c) micropipette tip; (d) photoelectrode; (e) LED lamp; (f) glass cell; and (g) 3D-printed cell cover.

The cell body was made of glass (5 mm thick), with dimensions of 7 cm \times 6 cm. The 3D printed cover of the cell, the electrode holder and the injector holder were printed in a MakerBot Mini Plus 3D printer (Makerbot, Boston MA, USA) using the poly(acetic acid) biodegradable (PLA) filament as printing material while maintaining the extruder temperature at about 215 °C. The injections of the glucose solutions were performed with aid of an electronic micropipette model Pipetman from Gilson (Middleton, USA) operating with a fixed dispensing rate of 6 $\mu\text{L s}^{-1}$ and an injection volume of 25 μL .

The p-Cu₂O/n-Cu₂O/FTO platform was employed for glucose determination in artificial saliva samples (Ringer's

solution) in order to evaluate the applicability of the light-assisted photoelectrochemical batch injection analysis (PEC-BIA) system.³⁶ The artificial saliva samples (Ringer's solution) were prepared in water with the following constituents and final concentrations: 9.0 g L⁻¹ NaCl (or ca. 0.150 mol L⁻¹); 0.4 g L⁻¹ KCl (or ca. 0.005 mol L⁻¹); 0.2 g L⁻¹ CaCl₂·6H₂O (or ca. 0.001 mol L⁻¹), and 0.2 g L⁻¹ NaHCO₃ (or 0.002 mol L⁻¹). The medium's pH was adjusted to 7.4 with 10% (v/v) HCl solution.³⁶ After preparation, the solution was stored under refrigeration (ca. 4 °C). The artificial saliva samples were diluted to 10% (v/v) in 0.1 mol L⁻¹ NaOH electrolyte and fortified with appropriate amounts of glucose before the photoelectrochemically-assisted batch injection analysis (PEC-BIA) measurements.

The electrochemical impedance spectroscopy (EIS) measurements were carried out in order to evaluate the electrochemical properties of the photoelectrodes. The EIS measurements were performed with the aid of an Autolab PGSTAT 128N Potentiostat/Galvanostat (Metrohm Autolab B. V. Utrecht, Netherlands) equipped with an FRA 2 module controlled by FRA software (version 4.9). The Mott-Schottky (M-S) analysis and Bode-phase measurements were performed in 0.1 mol L⁻¹ sodium sulfate. The effect of the light on the electrochemical behavior of the photoelectrochemical platforms was evaluated in 0.1 mol L⁻¹ NaOH containing 1000 $\mu\text{mol L}^{-1}$ of glucose. The Nyquist and Bode plots were recorded from 10⁻¹ to 10⁵ Hz under an AC amplitude of 0.01 V. The M-S measurements were performed changing the applied potential to the photoelectrode, maintaining the frequency constant. The electrochemical characterization of the photoelectrochemical platforms was also performed by cyclic voltammetry.

Results and Discussion

Raman and XRD characterization of the photoelectrochemical platforms

Figure 2 shows the Raman spectra for electrodeposited n-Cu₂O/FTO, p-Cu₂O/FTO, and p-Cu₂O/n-Cu₂O/FTO. As can be seen, similar spectra were obtained for all samples. According to the literature,^{37–42} all the observed phonon modes are characteristic of the crystalline Cu₂O, with cubic symmetry belonging to the space group Pn $\bar{3}$ m (O_h⁴). Although just one Raman-active mode with symmetry Γ_{25}^+ is expected in the Raman spectrum for this structure, infrared (with symmetries $\Gamma_{15}^{-(1)}$ and $\Gamma_{15}^{-(2)}$) and selection-rule-forbidden modes, such as the modes with symmetries Γ_{12}^- and Γ_{25}^- , can also be allowed due to local defects and intrinsic selection rule violation mechanism, which explains the presence of the extra modes. Therefore, we attributed the

peak at about 149 cm^{-1} as being from an infrared-allowed phonon mode with symmetry $\Gamma_{15}^{-(1)}$, the peak at 198 cm^{-1} as due to a two-phonon combination mode of Γ_{12}^- and Γ_{25}^- , and the intense line at about 218 cm^{-1} from the second-order overtone of the phonon with symmetry Γ_{12}^- ($2\Gamma_{12}^-$).³⁷⁻⁴⁰

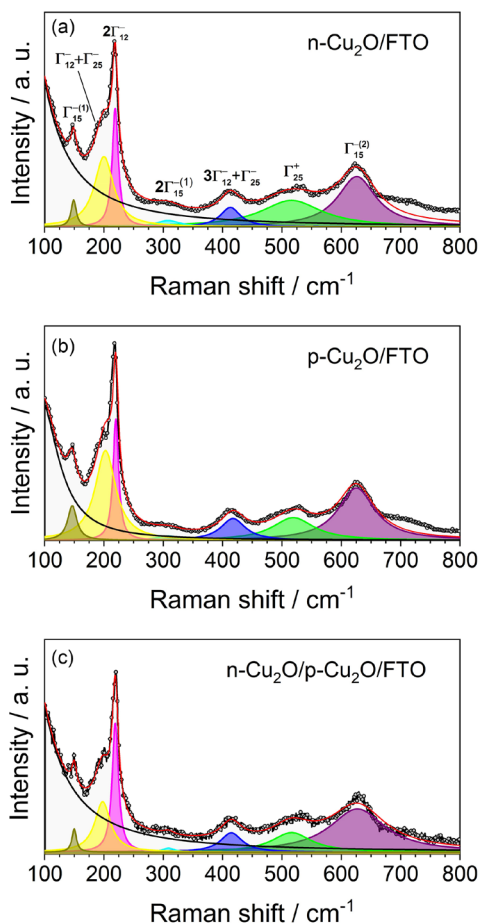


Figure 2. Raman spectra for the n-Cu₂O/FTO (a), p-Cu₂O/FTO (b) and p-Cu₂O/n-Cu₂O/FTO (c) platforms.

In addition, the weak peaks at about 308 cm^{-1} correspond to the second-order overtone mode $2\Gamma_{15}^{-(1)}$,³⁴ the peak at 414 cm^{-1} is assigned to a four-phonon mode $3\Gamma_{12}^- + \Gamma_{25}^-$,⁴¹ the peak at about 516 cm^{-1} is the Raman-active mode (Γ_{25}^+),^{41,42} and the signal at 626 cm^{-1} is attributed to the infrared-allowed mode $\Gamma_{15}^{-(2)}$.⁴¹

The X-ray diffraction patterns of all the Cu₂O samples electrodeposited on FTO substrate presented peaks from the cubic (Pn3m space group, PDF:00-005-0667) structure of the Cu₂O as well as peaks of the FTO substrate (Figure 3). The XRD patterns presented peaks (2θ) at 29.6° , 36.5° , 42.4° , 61.4° , and 73.6° indicative of the (110), (111), (200), (220) and (311) planes, respectively, which correspond to the cubic structure of Cu₂O. In addition, the intensity of the peak (111) is higher than the others indicating a preferential growth of the Cu₂O films along the (111) direction.⁴⁰⁻⁴³

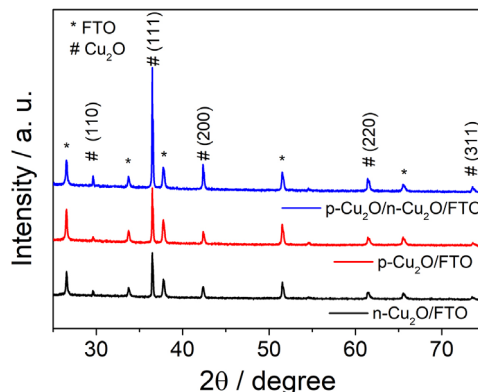


Figure 3. X-ray diffraction of the n-Cu₂O/FTO (black line), p-Cu₂O/FTO (red line) and p-Cu₂O/n-Cu₂O/FTO (blue line) platforms.

Electrochemical impedance spectroscopy investigation of the photoelectrochemical platforms

Electrochemical impedance spectroscopy measurements were performed to evaluate the effects of the type of Cu₂O semiconductor on the electrochemical properties of the platform. Figure 4 shows the Nyquist plots obtained for n-Cu₂O/FTO (Figure 4a), p-Cu₂O/FTO (Figure 4b), and p-Cu₂O/n-Cu₂O/FTO (Figure 4c) in 0.1 mol L^{-1} NaOH containing 1 mmol L^{-1} of glucose under dark (blue circle) and light (red square) conditions.

As can be seen in Figure 4, the p-Cu₂O/n-Cu₂O/FTO presented a semicircle diameter slightly lower than that observed to the n-Cu₂O/FTO, and p-Cu₂O/FTO photoelectrodes. In addition, the Figure 4 shows the effects of the incidence of light on the p-Cu₂O/FTO/n-Cu₂O/FTO platform. The Nyquist plots of p-Cu₂O/n-Cu₂O/FTO platform were affected by the incidence of light indicating that the harvested photons can promote electrons from valence band to conduction band of the semiconductor, which can contribute to a lower charge transfer resistance at the photoelectrode-electrolyte interface. The lower diameter semicircle observed for p-Cu₂O/FTO/n-Cu₂O/FTO under the incidence of light can be attributed to the more favorable electron transfer from the analyte to the holes in the p-Cu₂O/FTO/n-Cu₂O/FTO platform due to a better band alignment formed in the homojunction which facilitates the action of glucose as a hole scavenger. The electrons can diffuse from the n-Cu₂O film to the p-Cu₂O probably due to the higher Fermi level of the n-type film than the Fermi level of the p-Cu₂O film. Similarly, the photogenerated holes can diffuse from the p-type film to the n-type film. Thus, the flow of charges carriers between the films can establish an internal electrical field at the p-n interface. The internal potential developed in the interface can improve the charge separation and charge flow at the interface, which can also contribute to a low charge resistance.

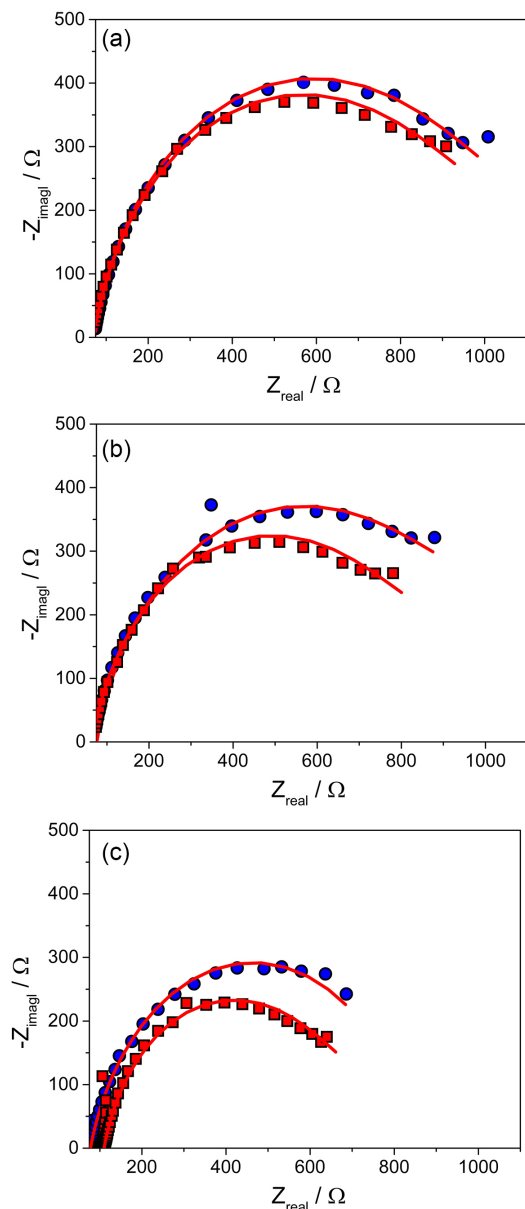


Figure 4. Nyquist plots for n-Cu₂O/FTO (a), p-Cu₂O/FTO (b) and p-Cu₂O/n-Cu₂O/FTO (c) in 0.1 mol L⁻¹ NaOH aqueous solution containing 1 mmol L⁻¹ of glucose under dark (blue circles) and light (red square) conditions. The red full lines represent the Nyquist semicircle fit.

Mott-Schottky plots were performed in 0.1 mol L⁻¹ Na₂SO₄ in order to evaluate the semiconductor type (p-type or n-type) and the flat-band potential (E_{fb}) (Figure 5). As can be seen from Figure 5a, the slope of the Mott-Schottky plot for n-Cu₂O/FTO platform was positive while the slope of the p-Cu₂O/FTO platform was negative indicating an n-type and p-type conductivity, respectively. On the other hand, the Mott-Schottky plot of the p-Cu₂O/n-Cu₂O/FTO platform (Figure 5b) presented co-existence of positive and negative slopes indicating that the photoelectrochemical platform presents the behavior of a p-n-junction, which is helpful for effective separation of electrons and holes.⁴⁴

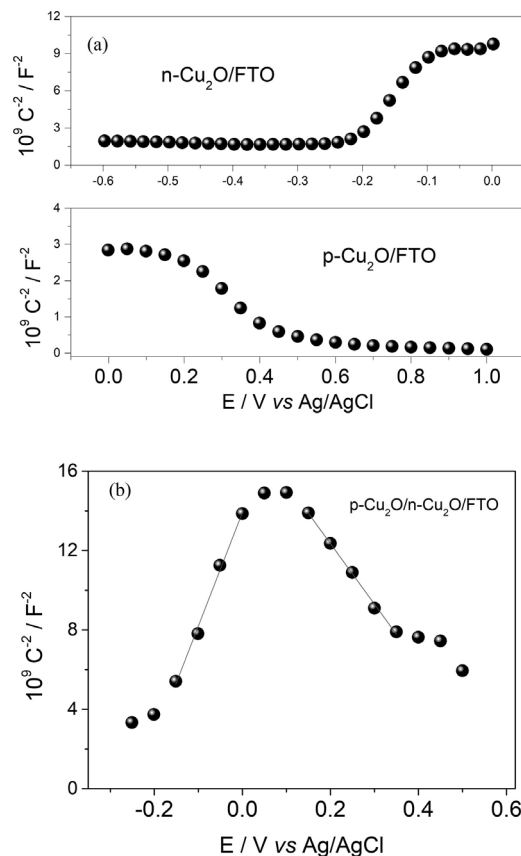


Figure 5. Mott-Schottky plots (C^{-2} vs. E) for n-Cu₂O/FTO and p-Cu₂O/FTO (a) and p-Cu₂O/n-Cu₂O/FTO (b) were obtained in 0.1 mol L⁻¹ Na₂SO₄.

The Mott-Schottky plot (C_{SC}^{-2} vs. E_{appl}) were constructed according to the following equation:⁴⁵

$$\left(\frac{1}{C_{SC}}\right)^{-2} = \pm \frac{2}{e_0 N_{a,d} \epsilon_0 \epsilon_r} \left(E_{appl} - E_{fb} - \frac{k_B T}{e_0}\right) \quad (1)$$

where e_0 is the elementary charge of the electron, $N_{a,d}$ is the acceptor or donor charge density, ϵ_0 is the vacuum permittivity, ϵ_r is the relative permittivity of Cu₂O, C_{SC} is the capacitance of the space charge layer, E_{appl} is the applied potential, k_B is the Boltzmann's constant, T is the absolute temperature, and E_{fb} is the flat band potential.

The flat band potentials of the n-Cu₂O type and p-Cu₂O type branches of Mott-Schottky plot obtained for the p-Cu₂O/n-Cu₂O/FTO platform were determined from the intercept of the Mott-Schottky plot under flat band condition considering that $E_{fb} = E_{appl} - \frac{k_B T}{e_0}$ and $\left(\frac{1}{C_{SC}}\right)^{-2} = 0$. The flat band potentials for n-Cu₂O and p-Cu₂O were about -0.269 V and +0.579 V, respectively. In addition, the Mott-Schottky plots of p-Cu₂O/n-Cu₂O/FTO platform presented an inverted “V-shape” as shown in the Figure 5b, indicating

the formation of p-n junctions in the p-Cu₂O/n-Cu₂O/FTO platform.⁴⁶⁻⁴⁸

Analytical performance and application of p-Cu₂O/n-Cu₂O/FTO photoelectrochemical platform for glucose determination in a PEC-BIA cell

In order to evaluate the analytical efficiency of the p-Cu₂O/n-Cu₂O/FTO photoelectrochemical platform to the glucose determination were performed successive batch injections of different concentrations of glucose with the aid of an electronic micropipette in the absence and the presence of light (Figure 6a).

As can be seen in the Figure 6b, the peak current increases linearly with the increase of the concentration of glucose concentrations ranging from 10 up to 1000 $\mu\text{mol L}^{-1}$ under the incidence of visible light biasing the platform at 0.6 V vs. Ag/AgCl. The calibration curve obtained for glucose determination by PEC-BIA based on p-Cu₂O/n-Cu₂O/FTO photoelectrochemical platform presented a linear behavior according to the following equation: $I_{\text{peak}} / \mu\text{A} = 14.643 + 0.768 ([\text{glucose}] / \mu\text{mol L}^{-1})$, for $n = 7$ and a correlation coefficient of 0.999.

The light-assisted determination of glucose with PEC-BIA system presented a limit of detection (LOD) of about 4.0 $\mu\text{mol L}^{-1}$ ($\text{LOD} = 3s_B/S$, in which s_B is the standard deviation of the blank and S is the slope of the calibration curve) and sensitivity of 0.768 $\mu\text{A L } \mu\text{mol}^{-1} \text{ cm}^{-2}$ which is competitive when compared to some recent works (Table 1)⁴⁹⁻⁵⁴ for glucose detection based on copper-based platforms. On the other hand, the sensitivity of the platform in the absence of light was 0.546 $\mu\text{A L } \mu\text{mol}^{-1} \text{ cm}^{-2}$ (Figure 6b).

As can be seen in the Figure 6b, the incidence of light on the p-Cu₂O/n-Cu₂O/FTO platform has resulted in an increase of the sensitivity of the system. The calibration

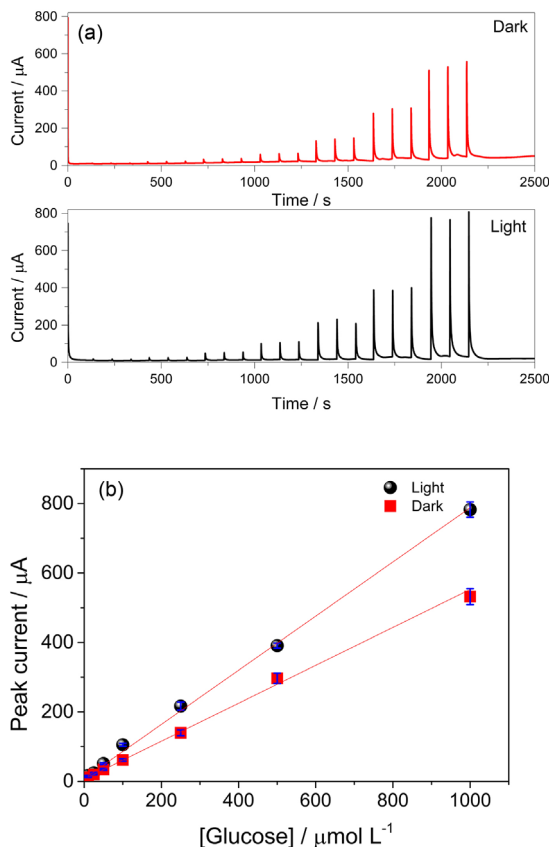


Figure 6. (a) Amperometric responses obtained after injection of glucose in the batch injection analysis system in the absence (red line) and presence of light (black line). (b) Analytical curve for glucose determination under the incidence of light (black circle) and under dark conditions (red square). Dispensing rate: 6 $\mu\text{L s}^{-1}$; injection volume: 25 μL ; and applied potential: 0.6 V vs. Ag/AgCl.

curves for the determination of glucose with the proposed p-Cu₂O/n-Cu₂O/FTO platform shows a higher slope under the incidence of light than under dark conditions (Figure 6b). The p-Cu₂O/n-Cu₂O/FTO can generate electron-hole couples under the incidence of light in order

Table 1. Comparison of some non-enzymatic sensors for the determination of glucose

Platform	Response range / (mmol L^{-1})	Sensitivity / ($\mu\text{A L mmol}^{-1} \text{ cm}^{-2}$)	Limit of detection / ($\mu\text{mol L}^{-1}$)	Reference
Octahedral Cu ₂ O	0.10-5.00	293.893	5.11	49
Cubic Cu ₂ O	0.10-2.50	22.669	12.80	49
Octahedral CQDs Cu ₂ O/Nafion/GCE	0.02-4.30	298	8.40	50
Octahedral Cu ₂ O	0.30-4.10	241	128.00	50
Cu ₂ O/GNs	0.30-3.30	285	3.30	51
Cu ₂ O/TNT	3.00-9.00	14.56	62.00	52
Cu/Cu ₂ O/CS	0.01-0.69	63.8	5.00	53
Cu/Cu ₂ O/CS	1.19-3.69	22.6	–	53
Au@Cu ₂ O	0.05-2.00	715	18.00	54
p-Cu ₂ O/n-Cu ₂ O/FTO	0.01-1.00	768	4.00	this work

CQDs: carbon quantum dots; GCE: glassy carbon electrode; GNs: graphene nanosheets; TNT: TiO₂ nanotubes; CS: carbon spheres; FTO: fluorine-doped tin oxide.

to increase the sensitivity of the photoelectrochemical platform for glucose detection. Thus, the p-Cu₂O/n-Cu₂O/FTO photoelectrochemical platform acts as a photoelectrochemical-assisted detector for the batch injection analysis since the electron-hole couples produced can improve the glucose oxidation.

Figure 7 shows a proposed scheme for the light assisted batch-injection analysis of glucose employing a p-Cu₂O/n-Cu₂O/FTO photoelectrochemical platform biased at 0.6 V vs. Ag/AgCl. The p-Cu₂O/n-Cu₂O/FTO photoelectrochemical platform harvests photons from incident light in order to produce electron-hole couples in p-Cu₂O and n-Cu₂O (equations 2 and 3).

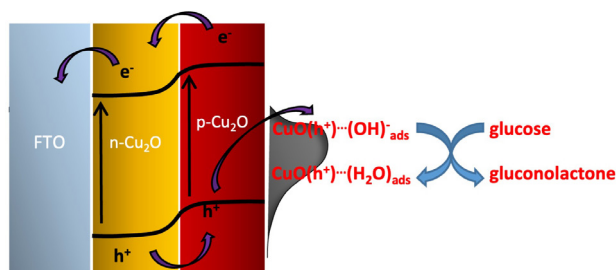
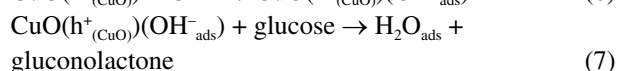
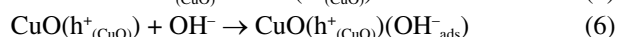
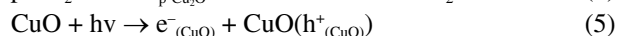
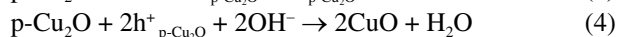
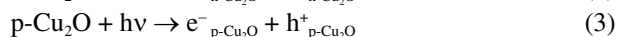
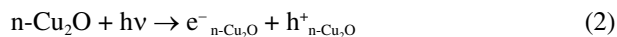


Figure 7. Schematic representation of the proposed mechanism for the oxidation of glucose on p-Cu₂O/n-Cu₂O/FTO photoelectrode surface under illumination.

The electrons photogenerated in the conduction band of p-Cu₂O are driven to the conduction band of n-Cu₂O to become further dragged by the FTO platform. Simultaneously, the holes photogenerated can be harvested by the glucose molecules at the interface photoelectrode-solution, and the holes photogenerated in n-Cu₂O can be transferred to the valence band of p-Cu₂O. Considering that the p-Cu₂O/n-Cu₂O/FTO photoelectrochemical platform was biased at 0.6 V, the Cu₂O at the semiconductor/electrolyte interface can be oxidized to form CuO. The photogenerated holes in CuO can then form ion pairs with OH⁻ with sufficient energy to promote the glucose oxidation. The following reactions are proposed for glucose oxidation on the p-Cu₂O/n-Cu₂O/FTO photoelectrochemical platform under the incidence of light:



The repeatability of the p-Cu₂O/n-Cu₂O/FTO photoelectrochemical platform biased at +0.6 V vs. Ag/AgCl

was evaluated performing successive photoelectrochemical-assisted batch injection analysis of 50 μmol L⁻¹ of glucose. The relative standard deviation (RSD) of the response of the p-Cu₂O/n-Cu₂O/FTO photoelectrochemical platform for three successive injections of glucose was about 2.9%. On the other hand, the reproducibility of the p-Cu₂O/n-Cu₂O/FTO photoelectrochemical platform for detecting glucose was about 3.5% for the photocurrents. The long-term stability of the proposed p-Cu₂O/n-Cu₂O/FTO photoelectrochemical platform was evaluated monitoring the response of the system for one month. It was observed that the p-Cu₂O/n-Cu₂O/FTO photoelectrochemical platform retained more than 95% of its initial response after one month.

The effects of some species frequently observed in formulations of artificial saliva samples on the response of the photoelectrochemical platform were investigated in order to evaluate the selectivity of the photoelectrochemical-assisted batch injection analysis of glucose exploiting the p-Cu₂O/n-Cu₂O/FTO photoelectrode. In this sense, the effects of potassium, sodium, calcium, magnesium, dihydrogen phosphate, ammonium, and chloride ions, as well as the interference of urea and amylase molecules on the response of the p-Cu₂O/n-Cu₂O/FTO photoelectrode were tested in a glucose/foreign specie ratio of 1/1, respectively. Recovery tests were performed applying the p-Cu₂O/n-Cu₂O/FTO photoelectrode in artificial saliva samples spiked with a known amount of glucose. The glucose concentration found in spiked samples was calculated using the standard addition method, and the concentration value found of 67.2 μmol L⁻¹ was in good agreement to spiked in sample of 70 μmol L⁻¹, having a detection recovery of 96%.

Conclusions

The present work describes at the first time the development of a photoelectrochemical-assisted batch injection analysis system exploiting a homojunction based on a p-Cu₂O/n-Cu₂O/FTO photoelectrode for glucose detection. The Raman spectra of n-Cu₂O and p-Cu₂O, electrodeposited on the FTO surface, indicated that they have the phonon frequencies characteristic of crystalline Cu₂O. The XRD patterns confirmed the crystalline character of the electrodeposits and that they preferentially grow along the (111). The Mott-Schottky analysis indicated that the n-Cu₂O shows the behavior of an n-type semiconductor while the p-Cu₂O electrodeposited sample presented the behavior of a p-type semiconductor. The p-Cu₂O/n-Cu₂O/FTO photoelectrode was successfully applied in photoelectrochemical assisted batch-injection analysis system for the determination of glucose in artificial saliva sample being a promising alternative method for glucose

determination with good sensitivity, wide linear-response range, low limit of detection, and good sensitivity.

Acknowledgments

The authors are grateful to FAPEMA (INFRA-03186/18; UNIVERSAL-01057/19; UNIVERSAL-01194/17), CNPq (308204/2018-2; 309828/2020-1), Instituto Nacional de Ciência e Tecnologia em Bioanálítica (465389/2014-7), and FINEP for financial support. The authors gratefully acknowledge the Analytical Center of UFMA that provided the FTIR spectra.

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Submitted: May 23, 2021

Published online: August 30, 2021

